

Abstract

- There are disclosed a photosensitive element comprising a support film which comprises a biaxially oriented polyester film and a photosensitive resin composition layer formed on one surface of the polyester film,
- 5 wherein a resin layer containing fine particles is formed on the opposite surface of the support film to which the photosensitive resin composition layer is formed, and said
- 10 photosensitive resin composition comprises
- (A) a binder polymer having a carboxyl group,
- (B) a photopolymerizable compound having at least one polymerizable ethylenically unsaturated group in the molecule, and
- 15 (C) a photopolymerization initiator,
- a photosensitive element roll, a process for the preparation of a resist pattern using the same, the resist pattern, a resist pattern-laminated substrate, a process for the preparation of a wiring pattern and the wiring pattern.